

QUANTUM OSCILLATIONS OF RESISTIVITY IN BISMUTH NANOWIRES

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Abstract

We studied the influence of uniaxial deformation on the transport properties of bismuth wires in the wide range of temperatures. Measurements of the resistance of bismuth nanowires with several diameters and different quality reveal oscillations on the dependence of resistance under uniaxial strain at $T = 4.2$ K. Amplitude of oscillations is significant (38%) at helium temperature and becomes smearing at $T = 77$ K. Observed oscillations originate from quantum size effect.

Evaluation of period of oscillations allows us to identify the groups of carriers involved in transport. Calculated periods of 42.2 and 25.9 nm satisfy approximately the ratio 2:1 for two experimentally observed sets of oscillations from light and heavy electrons.

1. Introduction

A lot of the investigations concerned with various nanostructures are motivated partially by the very interesting thermoelectric and magnetotransport properties of bismuth nanowires (NWs) that make them potentially useful for device applications. Theoretical calculations [1-3] predicted that Bi nanowires should have an enlarged thermoelectric figure of merit, which results from the quantum size effect, have induced extensive studies of Bi NWs. Under the quantum size effect (QSE), several fundamental macroscopic characteristics of solids exhibit an anomalous dependence on reduced size. Therefore, for subsequent applications, a precise determination of the size-dependent parameters of investigated nanostructures is required. If the decreased size of wires or films becomes comparable with the electron wavelength ($d \sim \lambda$), the transverse motion of carriers is quantized. Thus, the energy spectrum splits into subbands. When the discreteness of the energy subbands becomes significant, an oscillatory behavior of electron and hole density of states (DOS) as a function of thickness is expected for metal films [3, 4]. Oscillations of DOS are due to variation in number of the subbands with diameter. According to the theoretical considerations of the QSE [3, 4] all the transport coefficients which depend on the DOS should oscillate as a function of sample thickness with the period

$$\Delta d = h/2(2m_t^*E_F)^{1/2}, \quad (1)$$

where m_t^* is the transverse effective masses, and E_F is the Fermi level.

The main experimental results in the investigations of the QSE have been obtained for thin semimetal films. The first quantum size oscillations in the resistivity, Hall coefficient, and magnetoresistance with a period of 400 Å were observed in thin bismuth films [5]. Investigations [6] of bismuth films in large range of thickness (200-3000 Å) revealed that the period of the resistance oscillations varied from 40 to 250 Å with sample thickness. The difference in the period was attributed to the differences in the carrier concentrations due to growth conditions.

Quantum oscillations in the resistance of bismuth-antimony alloy films were registered under variation in both thickness and Sb concentration at a fixed thickness [7]. The concentra-

tion oscillations in a sample with constant thickness are explained by the change of the transverse quasi-momentum caused by composition variation in the Bi-Sb alloy. An other manifestation of the QSE [8] was observed while studying the thickness dependence of the ratio of the electron and hole density of states measured under electric field effect (EFE). The method allows a rather precise determination of the film thickness period of the oscillations, which is about 370 Å.

In most of the above-mentioned cases, QSE was shown as an oscillatory behavior of the resistance dependence on film thickness. As is pointed out in [9], a variation in the value of the band overlap should also produce an oscillatory behavior of the kinetic coefficients. The changes in band overlap in bulk Bi samples under deformation were described by Brandt [10]. The influence of the deformation on the band overlap changes was tested for bismuth films condensed on mica substrates [11]. Observed non-monotonous behavior of the resistance in bismuth films under sagging deformation is in a good agreement with the concept of QSE.

To our knowledge, up to now, most of the studies on quantum oscillations in transport properties of Bi nanostructures are concerned with thin films. The conditions of observation of the QSE on thickness dependences of the kinetic coefficients of thin wires are complicated by difficulties in the preparation of a series of samples with a small increment in thickness and identical characteristics of the bulk. Despite a lot of recently developed techniques for preparation of nanowires [1, 2, 12], the bulk characteristic data from different experiments depend not only on sample cross-sectional dimensions and crystallographic orientation but also on sample quality and purity, shell/matrix material, and annealing treatment. It is possible to observe the oscillations of kinetic parameters, due to size-quantized energy spectrum on the individual cylindrical nanowire under certain external influence, for example, by impurity doping or deformation.

The aim of this study was to study transport coefficients of individual bismuth nanowires under condition of QSE by applying uniaxial stress for tuning the electronic structure and inducing band overlap changes. According to the condition of QSE realization ($d \sim \lambda$), an oscillating behavior in transport coefficient of Bi samples is expected at diameters below 100 nm. One should note that uniaxial strain in Bi NWs promotes the increases in band overlap between L-electron pockets and T-holes pocket at constant band gap, in contrast to its decrease under QSE.

2. Experimental methods and samples

Long Pyrex-coated Bi wires were fabricated using the same improved variant of the Taylor method. This method, which is presently known as the glass-coated melt spinning method, consists in the melting of a metal in a glass tube by rf induction heating and drawing a glass capillary in which the molten metal is entrapped.

The wire axis is at an angle of about 19° with the bisector axis C_1 in the bisector-trigonal plane C_1C_3 . This orientation is the same as that observed in Bi nanowire arrays by Z. Zhang et al. [1]. Due to high elasticity of Pyrex capillaries, the limit of elastic stretching of the glass-coated Bi wires attains $\varepsilon = 3.5\%$ (in comparison for Bi whiskers $\varepsilon = 2.0\%$ [13] and for bulk Bi samples $\varepsilon = 0.4\%$ [14]). Due to small dimensions of glass-coated NWs, it was not possible to apply mechanical loading directly to them. For the measurements under uniaxial strain, the glass-coated wires with $d = 70\text{--}150$ nm and the length $L_0 = 2.0\text{--}3.0$ mm were mounted on an elastic bronze ring in a special insert with stretching device similar to the method used for whiskers [13]. The stretching was directed along the wire axis, i.e., close to the bisector axis C_1 . The measurements of resistance were performed using the two-probe

method. Resistance variation was defined as $\Delta R/R = (R - R_0)/R_0$, where R_0 is the value of resistance in a non-deformed state. Strain variation was defined as $\varepsilon = (L - L_0)/L_0$ where L_0 is the length of the wire in a non-deformed state. Electrical contacts to the wire ends were made by Wood's alloy. Low dc currents ($0.1 \mu\text{A} \leq I \leq 1 \mu\text{A}$) were used to make sure that the voltage of the sample was a linear function of the applied current.

3. Results and discussion

The studies of the strain dependences of the resistance $R(\varepsilon)$ at 4.2 K for wires with various diameters revealed the oscillating dependence of the resistance on applied deformation in wires with a diameter of 90 nm subjected to thermal annealing (Fig. 1). Since an oscillating behavior in transport coefficient of Bi wires is expected at diameters below 100 nm, we can suppose that observed oscillations are due to QSE. To our surprise, non-discernable and non-reproducible quantum oscillations on $R(\varepsilon)$ were observed in the thinner NWs with a diameter of 70 nm. The dependences of resistance versus uniaxial strain $R(\varepsilon)$ for Bi wires with the diameters $d \geq 100$ nm do not exhibit any oscillation and are similar to the one observed by us for thicker wires [13] and whiskers [11].

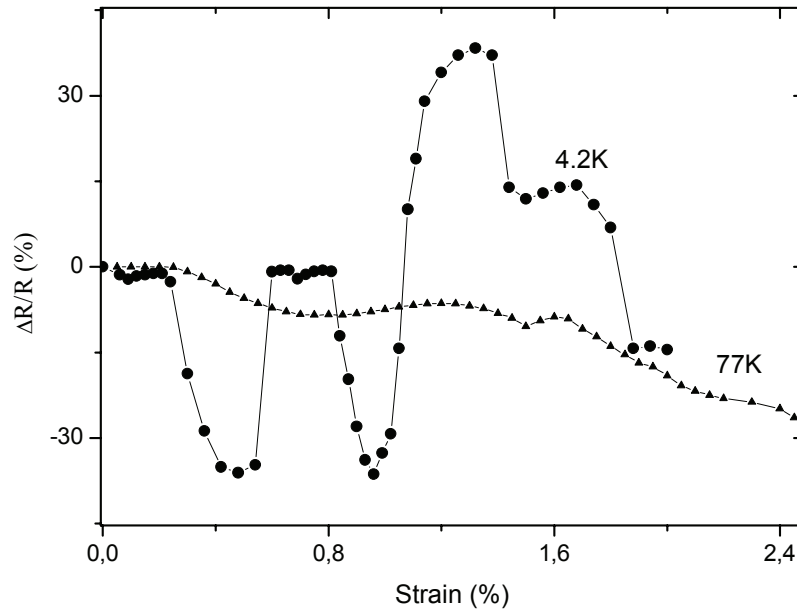


Fig. 1. Relative variation of the resistance as a function of applied strain for a 90-nm Bi nanowire measured at 4.2 K and 77 K.

Figure 2 shows the temperature dependences of the electrical resistance $R(T)$ for Bi NWs with various diameters. Observed $R(T)$ dependences are consistent with previous results for Bi wires [15] and Bi nanowire arrays [1]. Curve 2 in Fig. 2 presents the $R(T)$ dependence for a 90 nm NW after thermal treatment. History of the thermal treatment was not simple. Various variants of thermal treatment were tested and the optimal one was chosen. The NWs were annealed at 180°C for 10 h under vacuum with slow cooling back to room temperature. An evident increase in the value of residual resistance ratio (RRR) for the 90-nm wire after thermal treatment testified to an improved quality of annealed NWs. This supports the idea that the semiconducting behavior of $R(T)$ does not imply that a band gap opens even in the thin wires, a negative TCR may be rather an evidence of large defect density inside the as-prepared wires.

If we attribute the presence of oscillations on $R(\varepsilon)$ in Fig. 1 to the manifestation of QSE, in addition to the main condition $d \sim \lambda$ for QSE occurrence [4], we should consider some important requirements such as a small washing out of the discrete energy spectrum

$$\hbar/\tau \ll \Delta E, \quad (2)$$

and a small temperature smearing

$$kT \ll \Delta E, \quad (3)$$

where τ is the relaxation time, taking into account scattering both in volume and on the surface; ΔE is the distance between discrete energy subbands. Inequality (2) means a high mobility and/or large free path length for carriers involved in transport. It seems that all the requirements for QSE are satisfied for the annealed 90-nm wire at $T = 4.2$ K.

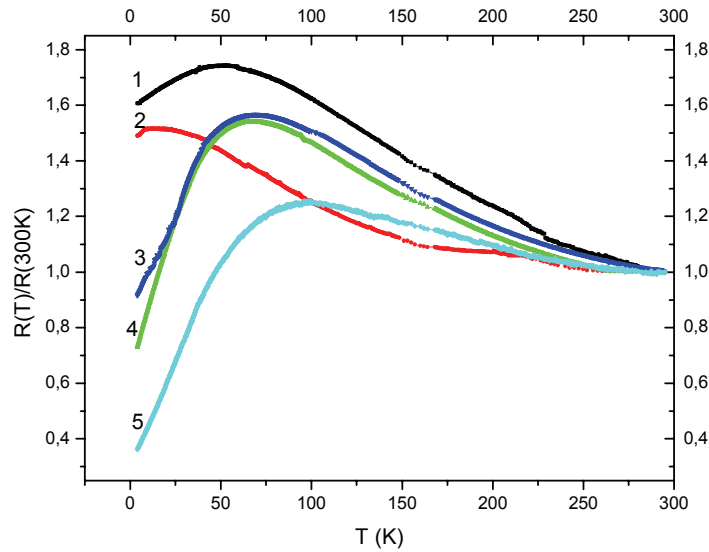


Fig. 2. Temperature dependence of resistance normalized to the resistance at 300 K for as-prepared Bi NWs: (1) $d = 90$ nm, (3) $d = 120$ nm and thermally annealed: (2) $d = 90$ nm, (4) $d = 120$ nm, (5) $d = 150$ nm.

The observed resistance oscillations were reproduced on all the wires with a diameter of 90 nm from the series of samples subjected to thermal annealing. As one can see from Fig. 1, the $R(\varepsilon)$ dependence at 4.2 K exhibits a modulating profile consisting of two sets of oscillations with different periods determined by different groups of carriers. First, we supposed that two different periods of oscillations are due to contribution of electrons and holes to electrical conductivity. It is known that difference in the periods of electron and hole quantum oscillations results from the anisotropic properties of Bi.

A rough evaluation of possible periods of quantum oscillations in the 90-nm bismuth wire was made by formula (1). The value of effective transverse mass of heavy and light electrons was used from the model of the subband structure calculated in [1] for the Bi nanowire arrays with the same crystal orientation, corresponding to [1011]. This is our case where three groups of carriers operate: heavy electrons from two equivalent pockets A and B, light electrons from pockets C, and heavy T-holes. According to [1], as the diameter of Bi nanowire arrays decreases below 100 nm, the band overlap between light and heavy electron pockets and T-hole pocket decreases in the different ways, thus resulting in the splitting of the L-point band edge. In this model, the band edge energy of each subband is determined by the average transverse effective mass approximated by the appropriate effective cyclotron mass. The values of effective masses calculated by authors of [1] are: $m^* = 0.00212m_0$ and $m^* = 0.00372m_0$ for light and

heavy electrons, respectively. Estimated periods for our 90-nm NW are: $\Delta d_1 = 42.2$ nm; $\Delta d_2 = 25.9$ nm and $\Delta d_3 = 16.0$ nm for light and heavy electrons and holes, respectively.

Coming back to measured quantum oscillations of resistance (Fig. 1) we note the period ratio of 2: 1 for two set of observed oscillations. Two of calculated periods 42.2 nm and 25.9 nm satisfy approximately the ratio 2: 1. The calculated value of 16.6 nm for hole period is overestimated as a result of using the value for hole transverse mass $m^* = 0.21m_0$ available for bulk Bi. The absence of quantum oscillations from holes can be caused by its small period and non-detectable amplitude versus background. Thus, we can suppose that quantum oscillations with large amplitude and period of 42.2 nm occur from the light electrons with smallest effective mass, and quantum oscillations with weak amplitude and period of 25.9 nm occur from heavy electrons from pockets A and B. A significant amplitude (38%) of resistance quantum oscillations with $\Delta d_1 = 42.2$ nm is due to the low quantum numbers of the subbands located below the Fermi energy level in the pocket C with light electrons. The vanishing of these oscillations at the deformation higher than 1% is suggestive of a change in the Fermi surface topology, known as an electronic topological transition (ETT) or Lifshitz transition. As a result of our previous investigations [16] of the changes in the Fermi surface topology under stress by means of Shubnikov-de Haas oscillation measurements, we have found the upward shift of the light electron pocket C relative to the other two pockets A and B up to its complete vanish at a high strain. Due to the continuing increase in the band overlap between L-electron pockets (A and B) and T-hole pocket, quantum oscillations with a period of 25.9 nm are detected at a strain higher than 1%.

If we attribute the presence of the oscillations on $R(\varepsilon)$ to the QSE manifestation, it is natural to make a brief analysis of correlation between the value of uniaxial strain and the period of observed oscillations Δd in 90-nm wires. Though the precise interrelation between applied uniaxial strain and Δd is not known, we try to follow the influence of strain on the Fermi level shifting through quantized subbands in electron pockets. In terms of previous results on ETT with the vanishing of one electron pocket, the work of extension of $\varepsilon = 0.96\%$ should be on the order of the energy shift of electron pocket C with strain. Since the measurements were made in the elastic deformation range, we may use the value of the elastic modulus for bulk Bi crystal along the bisector direction; thus, it is possible to determine the tensile load dependence P on the value of extension $\varepsilon = \Delta L/L_0$ which is approximately $P = 0.38$ GPa at $\varepsilon = 0.96\%$.

A rough estimation of value of the energy shift was made by using the values of shifting rate dE/dF of electron pockets under anisotropic deformation along the bisector direction for bulk Bi crystals calculated by authors in [17], which are: $dE/dF = 0.5$ meV/kg for pocket C and $dE/dF = -0.6$ meV/kg for pockets A and B. In our case, the value of energy shift was determined at a strain of 0.96%, where quantum oscillations with large period disappear. Calculated value is $dE \approx 19$ meV. Due to some involved calculational uncertainties, the value of $dE \approx 19$ meV is rather estimative; nevertheless, it is reasonable of the same order with value of Fermi energy level and of the band overlap (16 meV) for light electron pocket from the model of electronic band structure for 90 nm Bi NWs, advanced by authors of [1].

4. Conclusions

Systematic measurements of the resistance of bismuth nanowires with several diameters and different quality reveal oscillations on the dependence of resistance under uniaxial strain at $T = 4.2$ K. Amplitude of oscillations is significant (38%) at helium temperature and becomes smearing at $T = 77$ K. Observed oscillations originate from the quantum size effect.

The absence of quantum size oscillations in the resistance dependence for 70-nm wires can be explained partially by scarce number of light electrons responsible for oscillations with decreasing diameter [1] and partially by imperfection of the nanowires.

A simple evaluation of period of oscillations allows us to identify the groups of carriers involved in transport. Calculated periods of 42.2 and 25.9 nm satisfy approximately the ratio 2:1 for two experimentally observed sets of oscillations from light and heavy electrons.

The importance of the quantum size effect manifestation in the resistance dependence on strain goes beyond studying the structure of electron spectrum; it can also be applied to investigate the spectrum of phonons. With a view to elucidate some aspects of the practical use of nanowires, we plan the further investigations under strain of the thermopower, which at low temperature may be due to the diffusive or phonon drag mode of carrier interaction.

Acknowledgements

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